

Excitonic effects at the direct band gap of Ge

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Analysis of Femtosecond Pump-Probe Ellipsometry Data of Ge and Si

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Outline

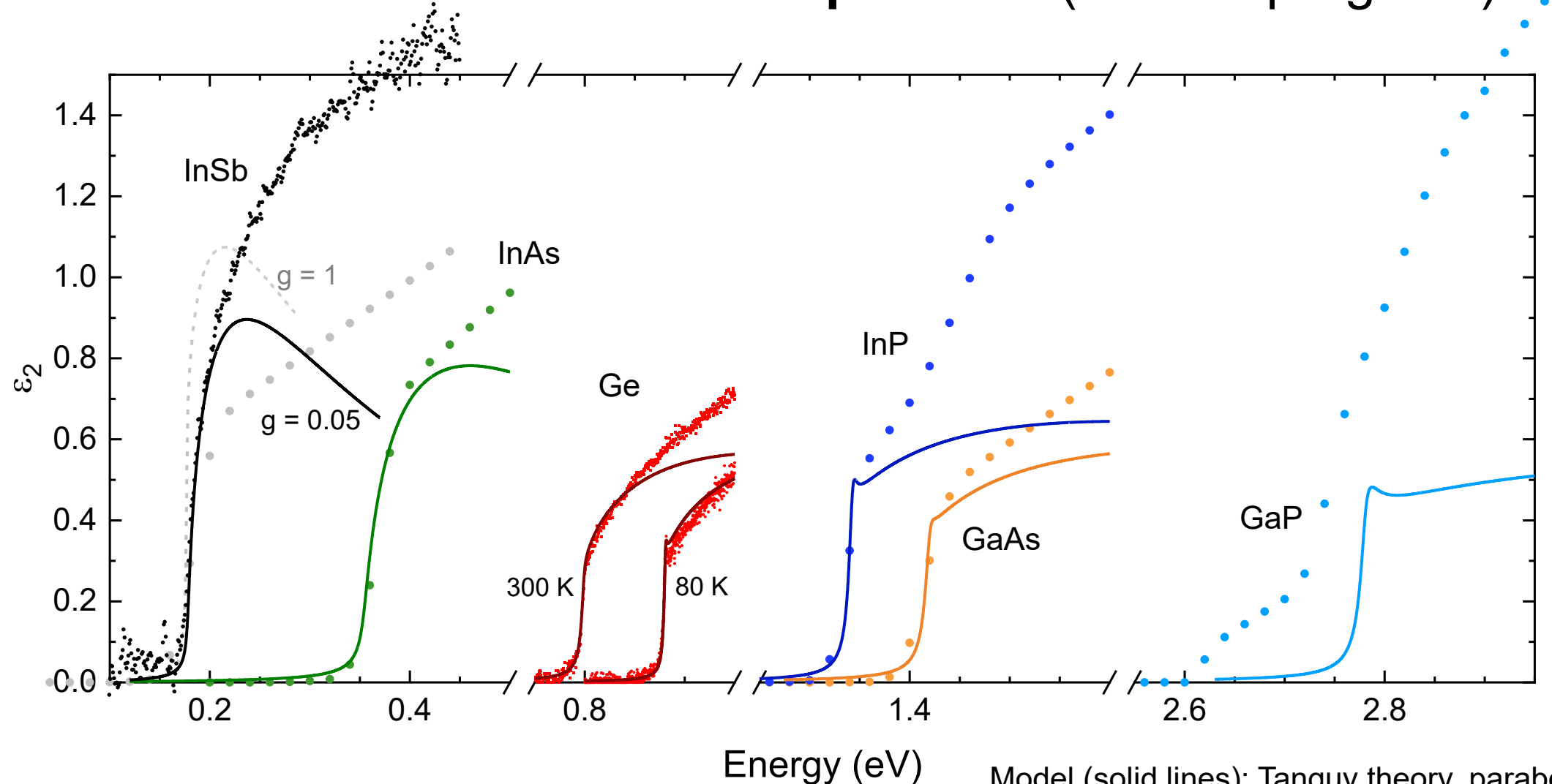
Part 1: Excitonic effects at the direct band gap of Ge

- Second derivative analysis using linear filters
- Tanguy-Elliott model with parameters from $k \cdot p$ theory
- Fit results: Energies and broadening as function of temperature

Part 2: Analysis of the transient dielectric function of Ge and Si from pump-probe spectroscopic ellipsometry

- Critical point parameters as functions of delay time
- Coherent acoustic phonon oscillations

Motivation: Model of the direct band gap of various semiconductors at room temperature (work in progress)



Model (solid lines): Tanguy theory, parabolic bands
 Symbols: Experimental data from NMSU and UNL

C. Tanguy, Phys. Rev. B **60**, 10660 (1999)

J. Menéndez, D. J. Lockwood, J. C. Zwinkels, M. Noël, Phys. Rev. B **98**, 165207 (2018)

P. Yu and M. Cardona, *Fundamentals of Semiconductors*, (Springer, Heidelberg, 2010)

Tanguy-Elliott model to consider excitonic effects

R. J. Elliott, Phys. Rev. **108**, 1384 (1957)
C. Tanguy, Phys. Rev. B **60**, 10660 (1999)

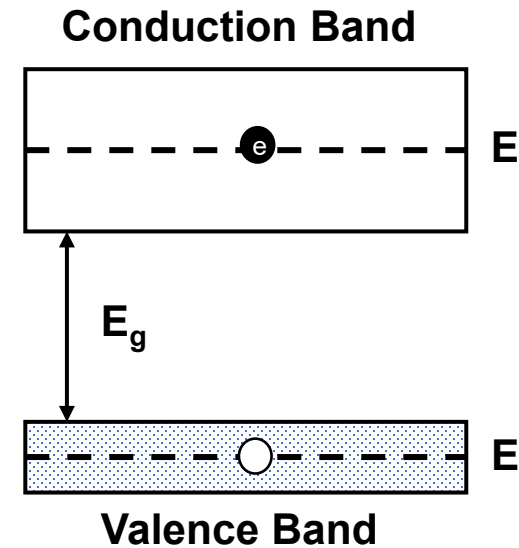
$$\epsilon(E) = \frac{A \sqrt{R}}{(E + i\Gamma)^2} [\tilde{g}(\xi(E + i\Gamma)) + \tilde{g}(\xi(-E - i\Gamma)) - 2\tilde{g}(\xi(0))]$$

$$\tilde{g}(\xi) = \underbrace{-2\psi\left(\frac{g}{\xi}\right)}_{\text{unbound}} - \frac{\xi}{g} - \underbrace{2\psi(1 - \xi)}_{\text{bound}} - \underbrace{\frac{1}{\xi}}_{\text{interband}}$$

$$\xi(z) = \frac{2}{\left(\frac{E_0 - z}{R}\right)^{1/2} + \left(\frac{E_0 - z}{R} + \frac{4}{g}\right)^{1/2}}$$

$$\psi(x) = \frac{d \ln \Gamma(x)}{dx} \quad (\text{Digamma function})$$

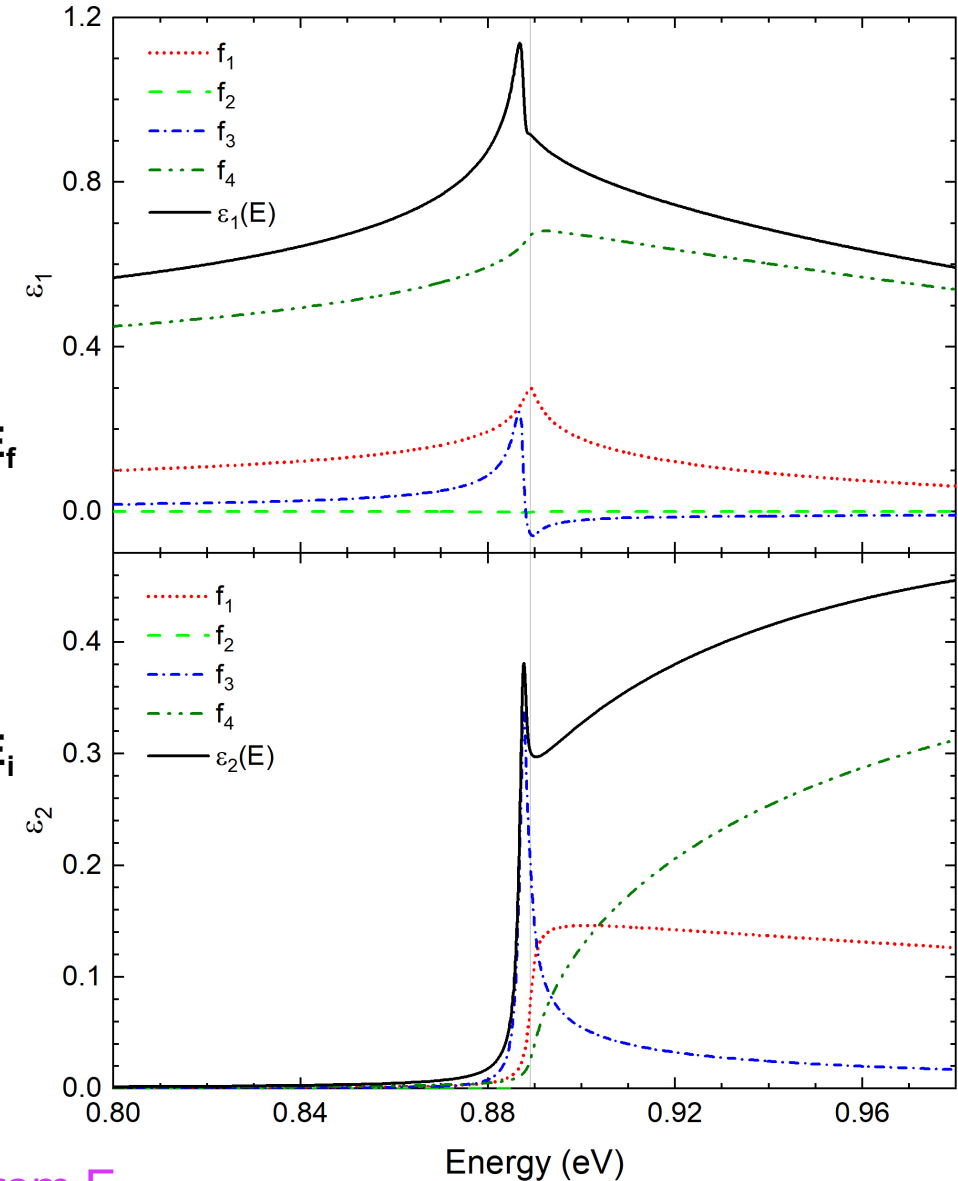
Energy ↑



Heavy hole (hh) and light hole (lh):

$$\epsilon(E) = \epsilon_{hh}(E) + \epsilon_{lh}(E) + 1 + \frac{A_1}{1 - B_1 E^2}$$

Sellmeier term to consider contributions from E_1

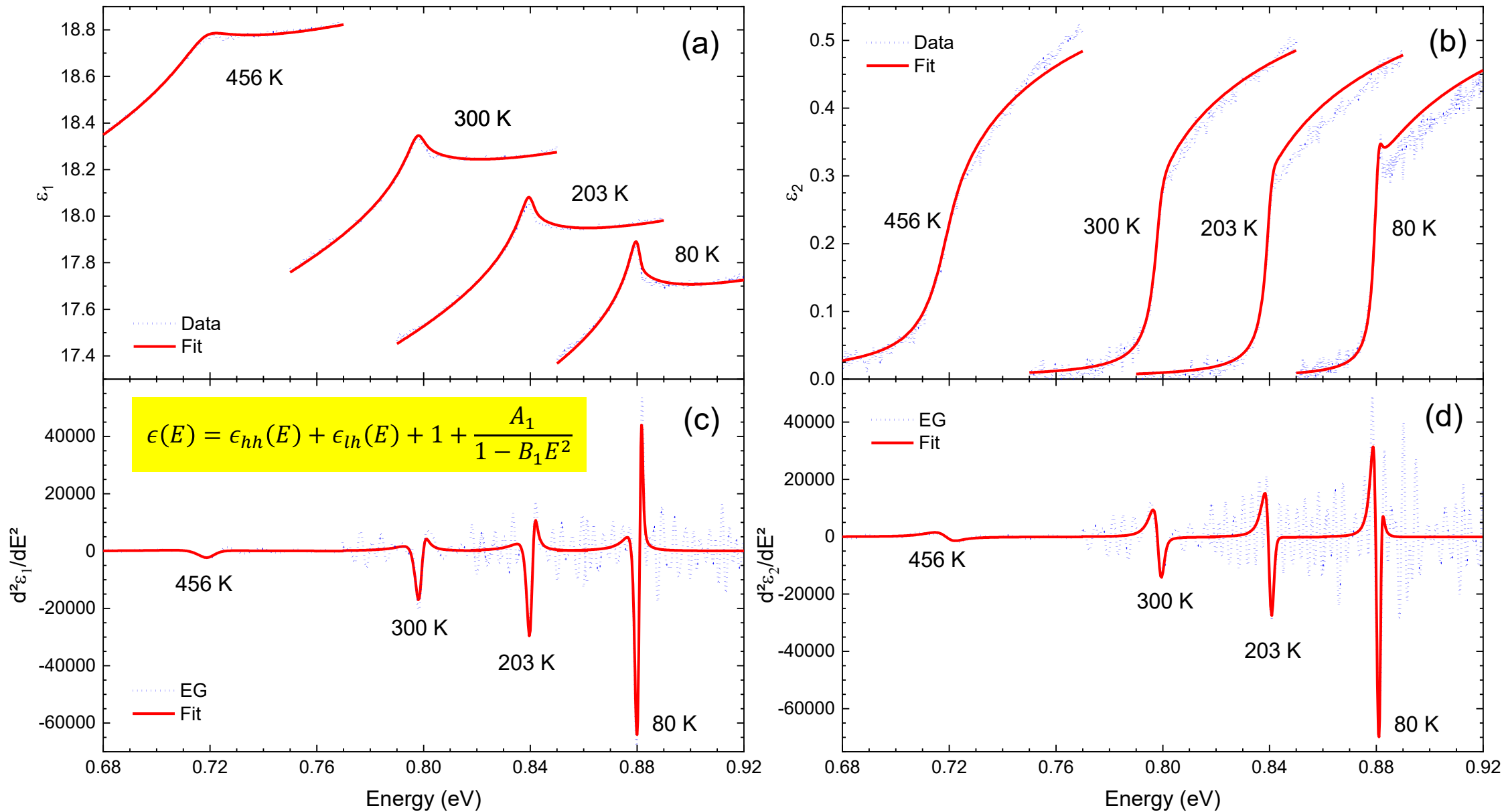


Parameters from k·p theory for semiconductors

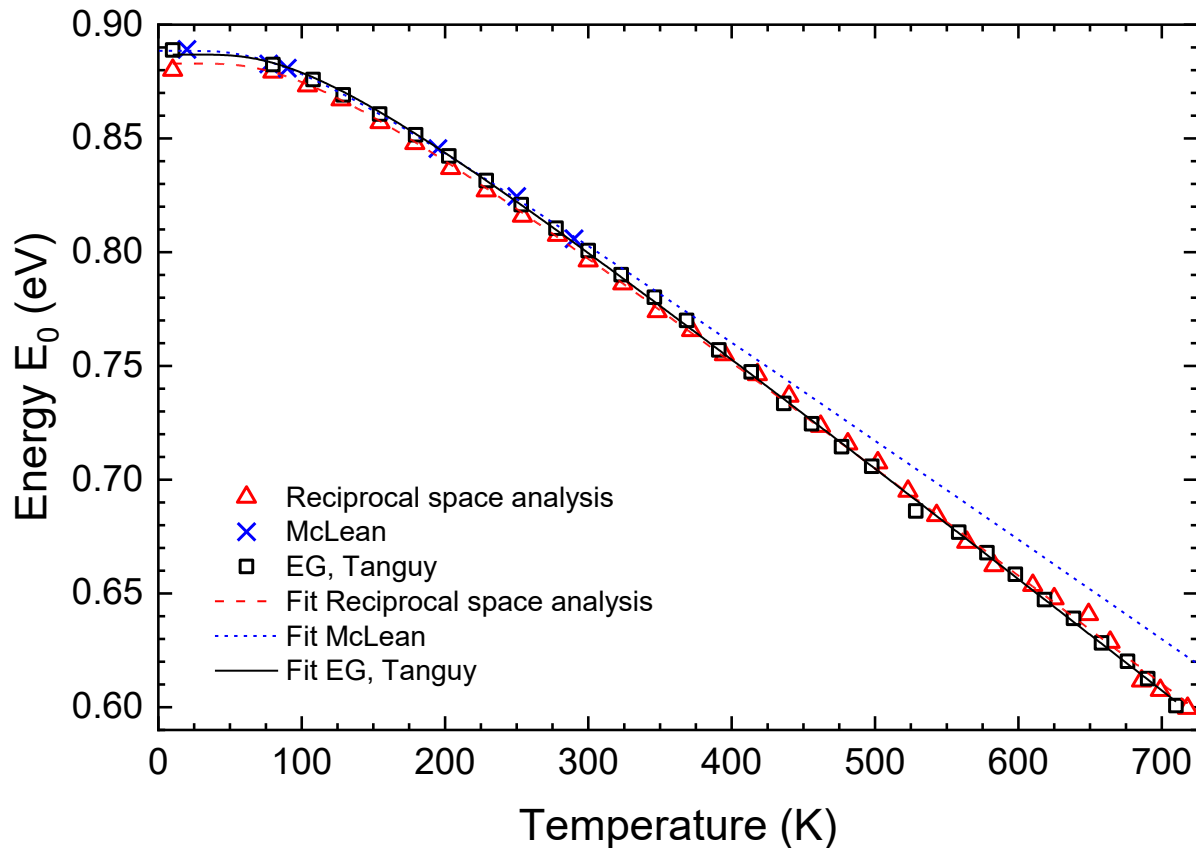
- **Effective masses:** $\frac{1}{\mu_{hh}} = \frac{1}{m_{hh}} + \frac{1}{m_e}$ and $\frac{1}{\mu_{lh}} = \frac{1}{m_{lh}} + \frac{1}{m_e}$
- **Excitonic binding energy:** $R_{hh} = \frac{\mu_{hh}}{\epsilon_r^2} 13.6 \text{ eV}$
 $R_{hh} \approx 2 \text{ meV}$ and $R_{lh} \approx 1 \text{ meV}$ at 10 K
- **Matrix element** $E_P = \frac{2P^2}{m_0}$ calculated via $\frac{1}{m_e} = \frac{1}{m_0} + \frac{E_P}{3m_0} \left[\frac{2}{E_0} + \frac{1}{E_0 + \Delta_0} \right]$
- **Amplitude:** $A_{hh} = \frac{e^2 \sqrt{m_0}}{\sqrt{2\pi\epsilon_0} \hbar} \mu_{hh}^{3/2} \frac{E_P}{3}$ with $E_P \approx 25 \text{ eV}$
- **Parameters at 10 K:**

$m_{e\Gamma}$	m_{hh}	m_{lh}	μ_{hh}	μ_{lh}	A_{hh}	A_{lh}	R_{hh} (meV)	R_{lh} (meV)
0.037	0.42	0.045	0.034	0.020	0.78	0.36	1.9	1.1

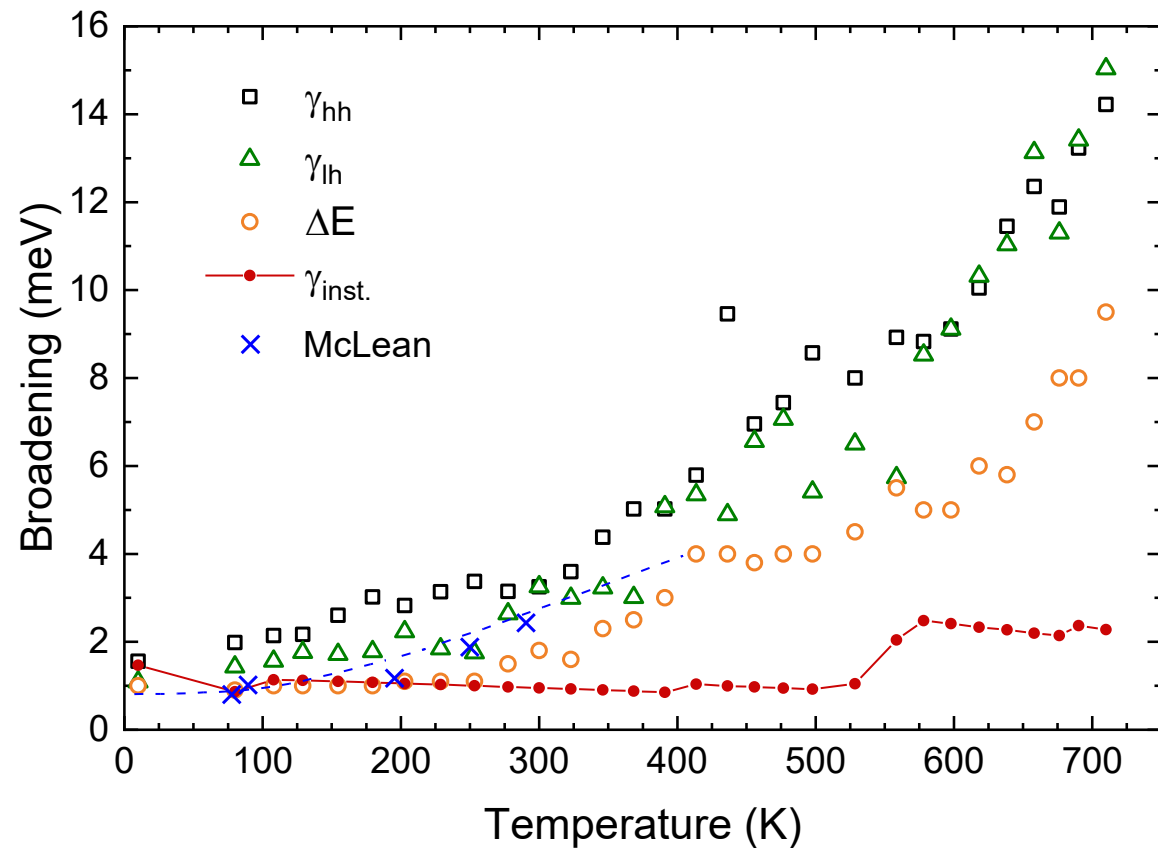
Fit results for Ge



Temperature dependence of the direct band gap of Ge



$$E(T) = E_a - E_b \left[\frac{2}{e^{\frac{E_{ph}}{kT}} - 1} + 1 \right]$$



$$\Gamma(T) = \Gamma_a + \Gamma_b \left[\frac{2}{e^{\frac{E_{ph}}{kT}} - 1} + 1 \right]$$

L. Viña, S. Logotheidis, M. Cardona, Phys. Rev. B **30**, 1979 (1984)

C. Emminger, F. Abadizaman, N.S. Samarasingha, T.E. Tiwald, S. Zollner, J. Vac. Sci. Technol. B **38**, 012202 (2020)

T. P. McLean, *Progress in Semiconductors*, (Heywood, London, 1960);

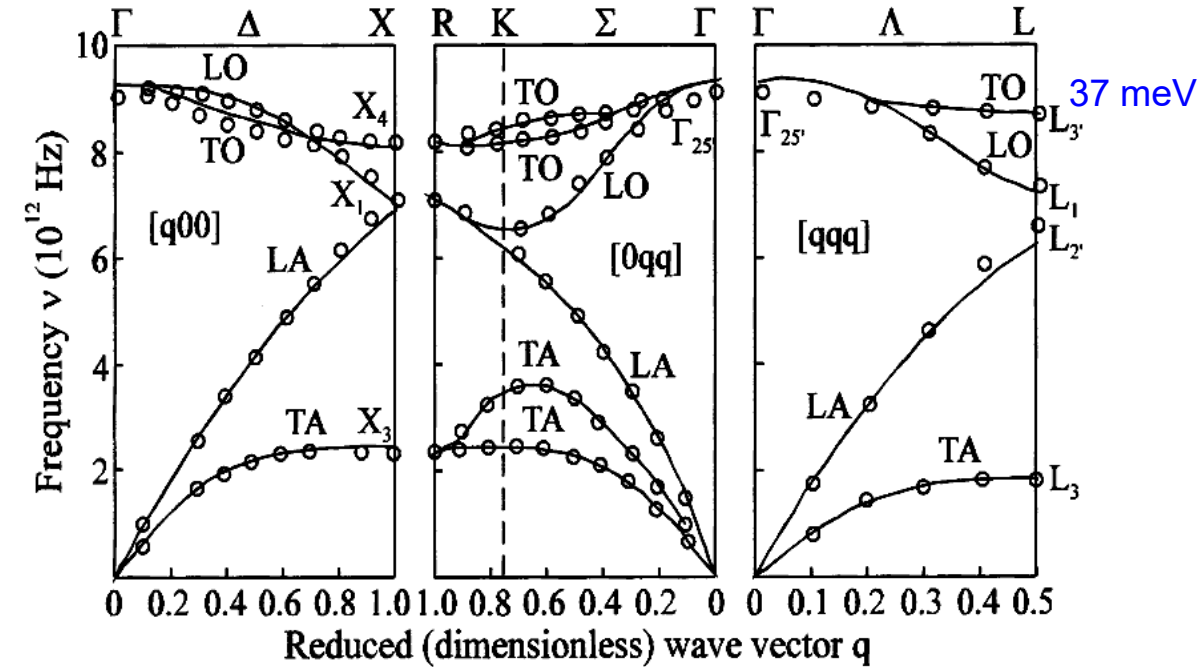
T. P. McLean and E. G. S. Paige, J. Phys. Chem. Solids **23**, 822 (1962)

Electron-LA phonon and hole-optical phonon intravalley scattering

Scattering mechanism	Scattering/relaxation time Normalizing constant
Acoustic phonon Deformation potential	$\tau_{ac} = 2(2\pi)^{1/2} \rho \hbar^4 s^2 [3E_1^2 m^{*3/2} (300k_B)^{3/2}]^{-1}$
	$E_1 = 11.4 \text{ eV}$ $\rho = 5.32 \text{ g/cm}^3$ $s = \frac{u_{lo}}{3} + \frac{2u_{tr}}{3} = 3.9 \times 10^3 \text{ m/s} \dots \text{ ellipsoidal \& warped bands}$ $m_{e\Gamma} = 0.037 m_0 \dots \text{ effective mass of the electron at } \Gamma$

Optic phonon Nonpolar	$\tau_{op} = 2(2\pi)^{1/2} \rho \hbar^3 \omega_o [\exp(\theta_o/300) - 1] \times [3D_o^2 m^{*3/2} (300k_B)^{1/2}]^{-1}$
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$m_{lh} = 0.045 m_0$
 $m_{hh} = 0.42 m_0$
 $a = 5.66 \text{ \AA}$
 $d_0 = 37 \text{ eV}$ (Pötzt and Vogl 1981)
 $D_0 = d_0/a = 7.53 \text{ eV/\AA}$
 $\omega_0 = 9 \text{ THz} = 37 \text{ meV}$



Weber W., Phys. Rev. **B15**, 10 (1977) 4789-4803.

Scattering	10 K		300 K		800 K	
	τ (fs)	Γ (meV)	τ (fs)	Γ (meV)	τ (fs)	Γ (meV)
Electrons-LA phonons	5×10^5	6×10^{-4}	3500	0.093	1400	0.23
hh-optical phonons	10^{21}	10^{-19}	180	1.8	35	9.5
lh-optical phonons	10^{22}	10^{-21}	5900	0.056	1400	0.23

W. Pötzt and P. Vogl, Phys. Rev. B **24**, 2025 (1981)

L. Reggiani, *Hot-Electron Transport in Semiconductors* (Springer, Berlin, 1985)

R. R. Alfano, *Semiconductors Probed by Ultrafast Laser Spectroscopy Vol. 1*, (Academic Press, London, 1984), chapter by B. R. Nag

Scattering of electrons with LA phonons at the L-point

Scattering rate for intervalley scattering (Conwell 1967): $\frac{1}{\tau} = N_V \frac{D^2 m_{\text{eff}}^{1.5}}{\sqrt{2\pi\hbar^2 \rho E_{\text{ph}}}} \sqrt{\Delta E - E_{\text{ph}}} \left(1 + \frac{2}{e \frac{k_B E_{\text{ph}}}{T} - 1} \right)$

m_{eff} : effective electron mass for final state for a single valley

$$m_{\text{eff}} = (m_l m_t^2)^{\frac{1}{3}} = (1.6 \cdot 0.08^2)^{\frac{1}{3}} m_0 = 0.22 m_0$$

$$\Delta E = 0.8 \text{ eV} - 0.66 \text{ eV} = 0.139 \text{ eV at RT}$$

$$\Delta E = 0.889 \text{ eV} - 0.742 \text{ eV} = 0.147 \text{ eV at low T}$$

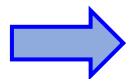
$$D = 6.5 \text{ eV/\AA at RT}$$

$$D = 3.0 \text{ eV/\AA at low T}$$

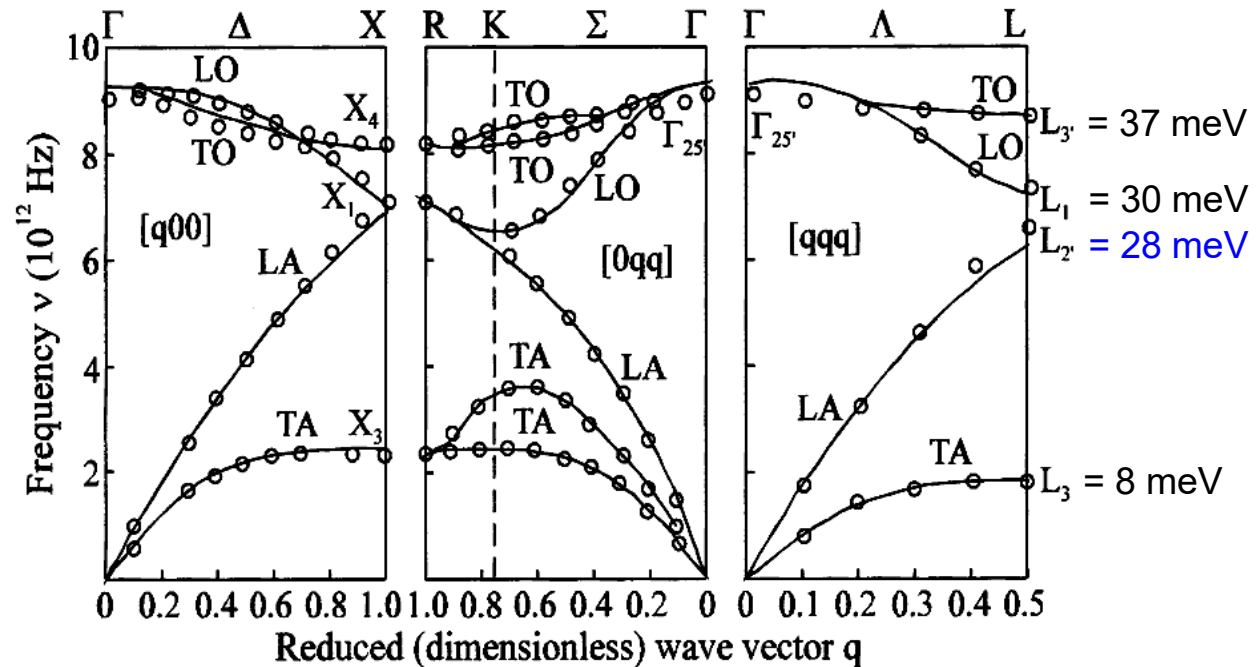
$$\rho = 5.32 \text{ g/cm}^3$$

$$E_{\text{ph}} = 28 \text{ meV}$$

$$N_V = 4$$

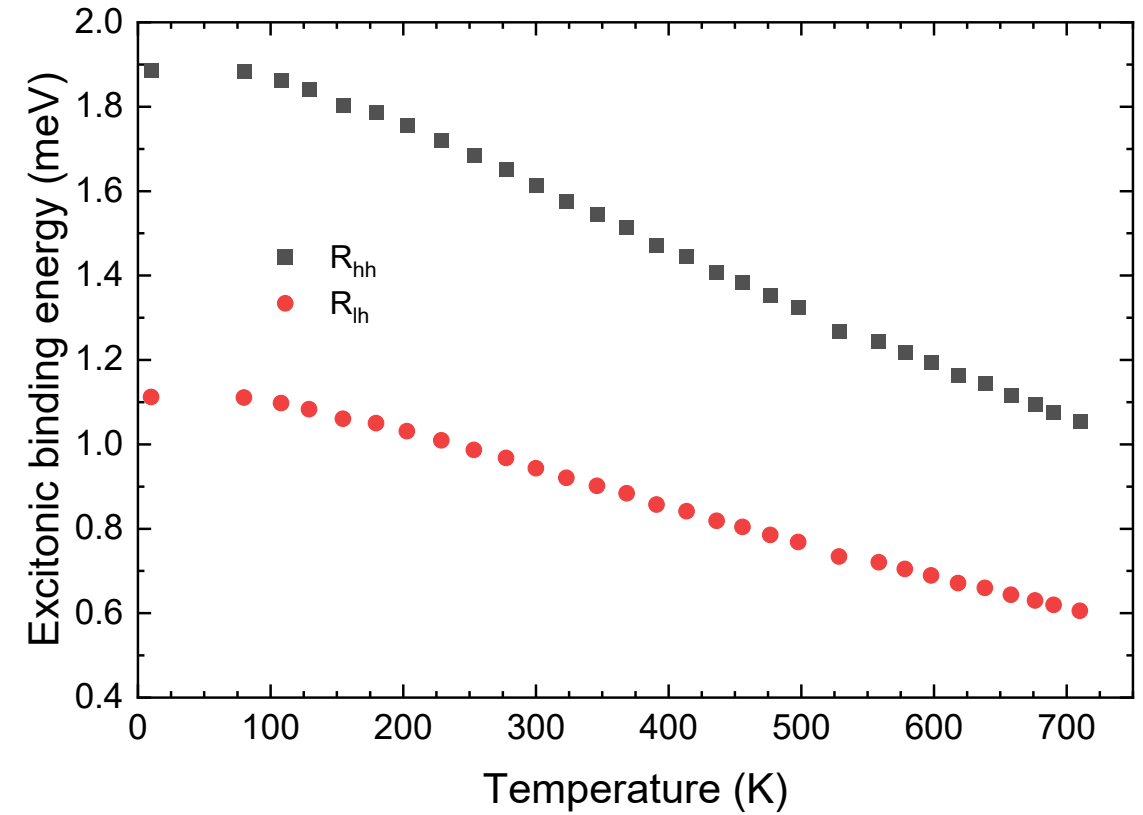
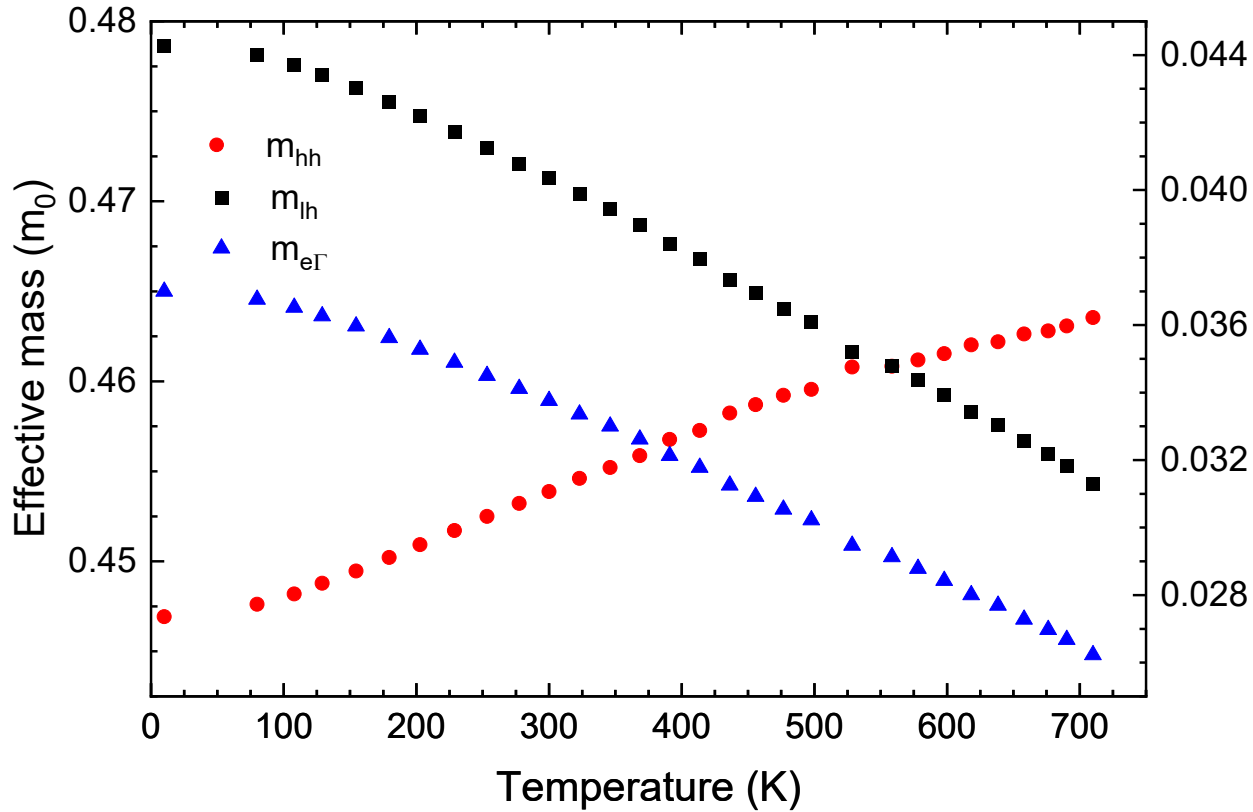


	300 K	10 K
τ (fs)	470	1050
Γ (meV)	0.70	0.31



Weber W., Phys. Rev. **B15**, 10 (1977) 4789-4803.

Temperature dependence of the effective masses and Rydberg energies



$$\frac{1}{m_{e\Gamma}} = \frac{1}{m_0} + \frac{E_P}{3m_0} \left[\frac{2}{E_0} + \frac{1}{E_0 + \Delta_0} \right]$$

$$\frac{1}{m_{hh}} = \frac{1}{\hbar} \left[-2A + 2B \left(1 + \frac{2|C|^2}{15B^2} \right) \right]$$

$$\frac{1}{m_{lh}} = \frac{1}{\hbar} \left[-2A - 2B \left(1 + \frac{2|C|^2}{15B^2} \right) \right]$$

$$A = 1 - 1/3 \left[\frac{E_P}{E_0} + \frac{2E_Q}{E'_0} \right]$$

$$B = 1/3 \left[-\frac{E_P}{E_0} + \frac{E_Q}{E'_0} \right]$$

$$C^2 = \frac{4E_P E_Q}{3E_0 E'_0} + \Delta$$

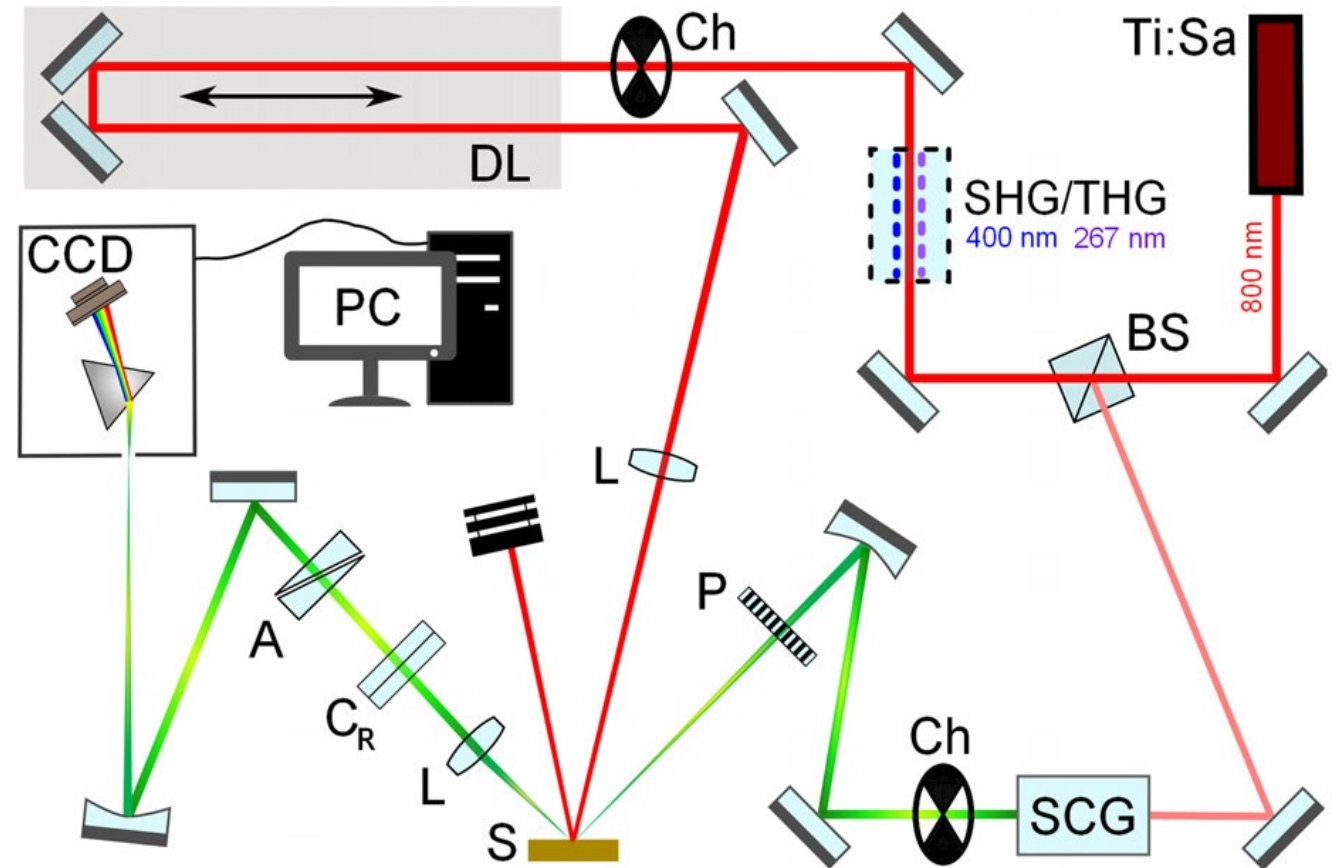
G. Dresselhaus, A. Kip, C. Kittel, Phys. Rev. **98**, 368 (1955)

J. Menéndez, D. J. Lockwood, J. C. Zwinkels, M. Noël, Phys. Rev. B **98**, 165207 (2018)

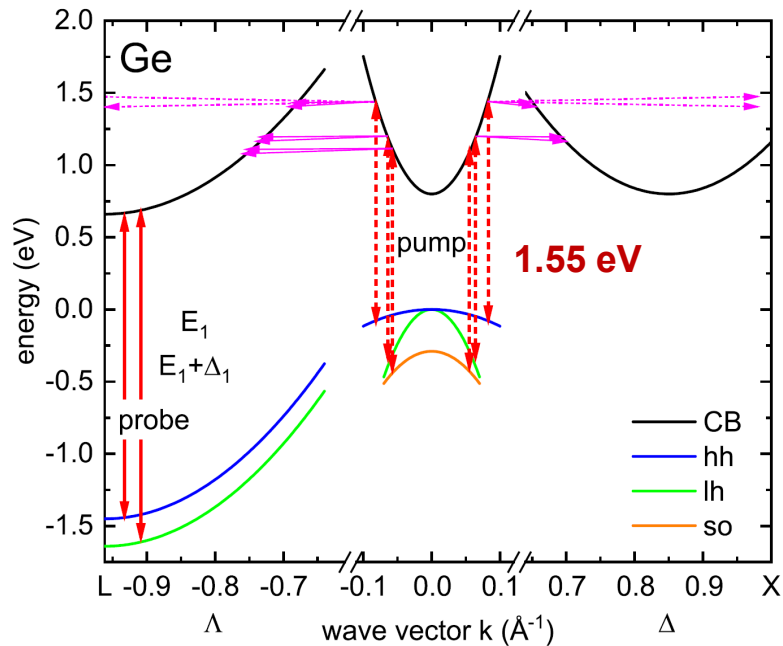
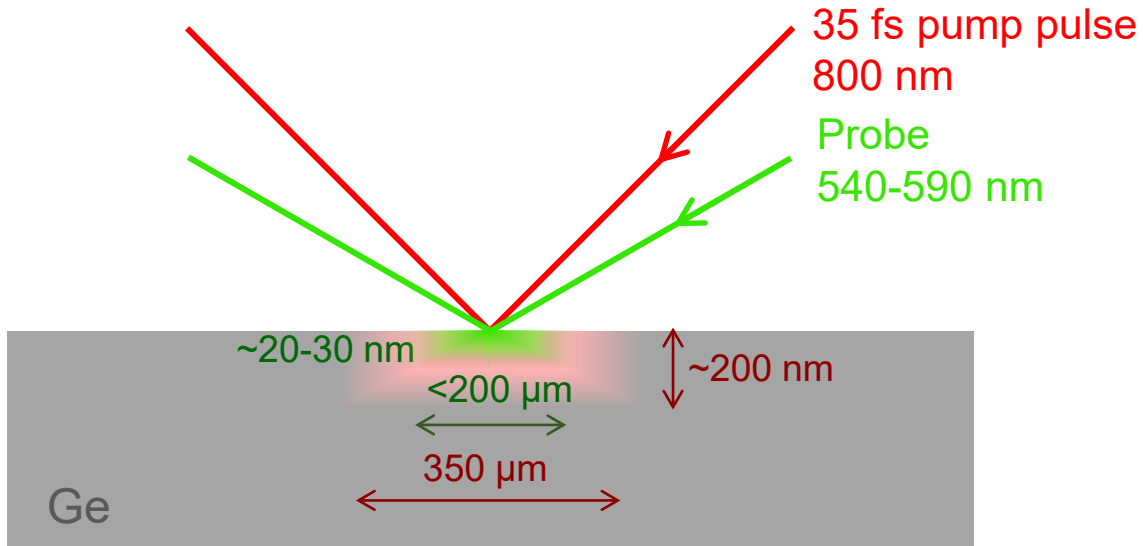
P. Yu and M. Cardona, *Fundamentals of Semiconductors*, (Springer, Heidelberg, 2010)

Pump-probe spectroscopic ellipsometry setup

- Pump pulse: 266, 400, and 800 nm
- 35 fs laser pulses
- Repetition rate: 1 kHz
- Pulse energy: up to 6 mJ
- Carrier density: 10^{20} cm^{-3}
- Time resolution: 120 fs (oblique incidence)
- Spectral range: 1.7 – 3.5 eV
- Probe beam diameter $< 200 \mu\text{m}$
- Pump beam diameter $\sim 350 \mu\text{m}$

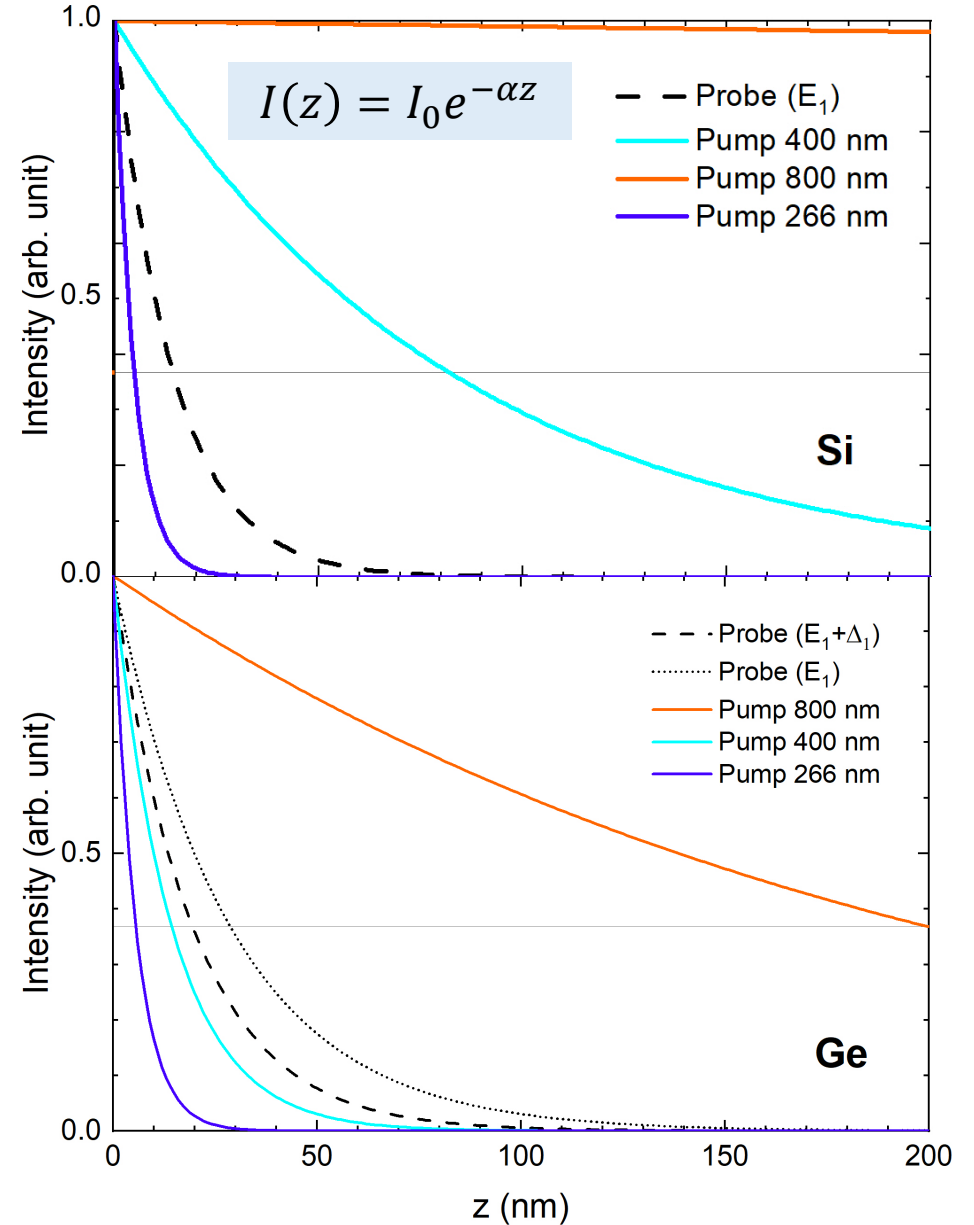


Penetration depth of probe and pump beams

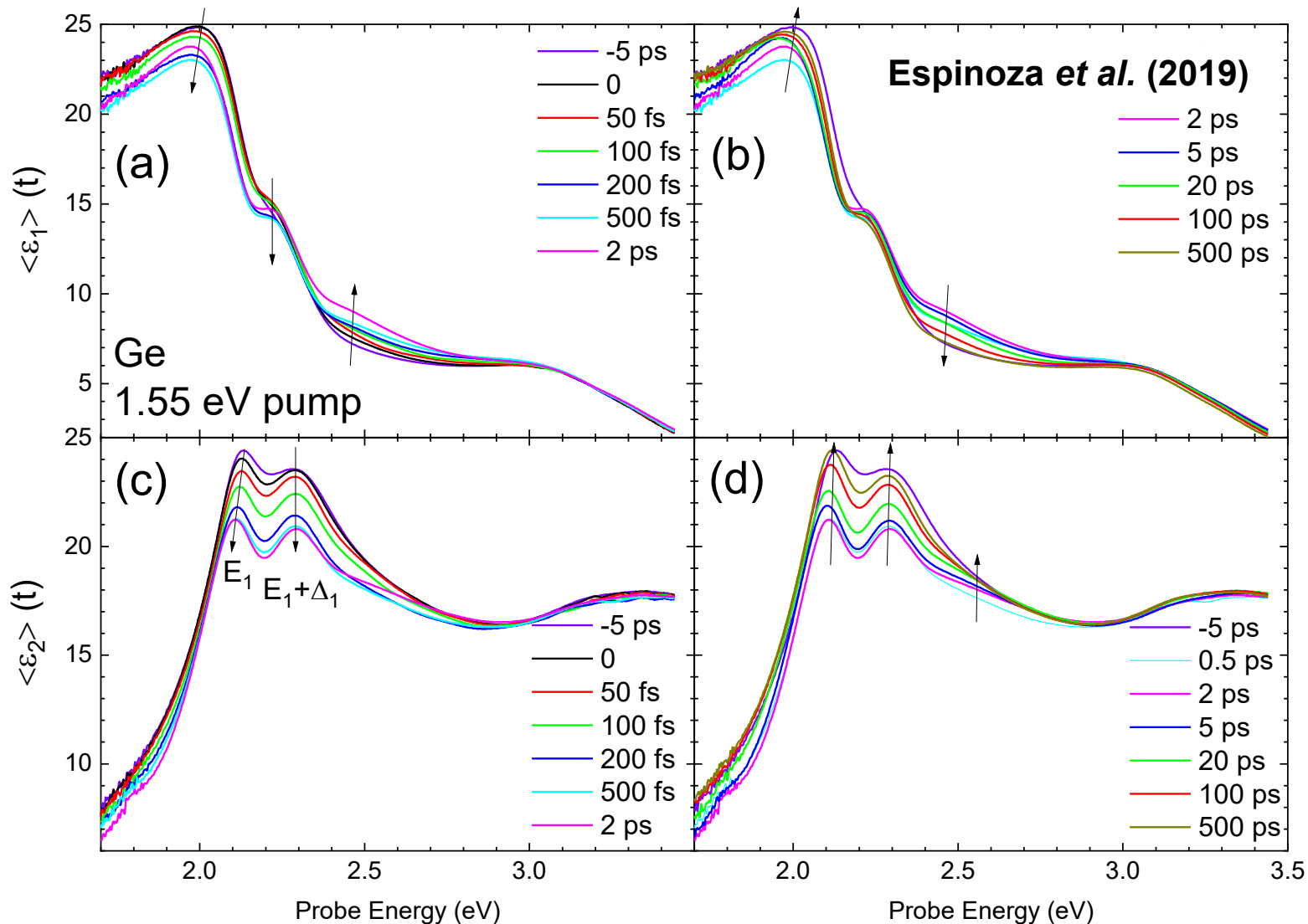


Carrier density:
 10^{20} cm^{-3}

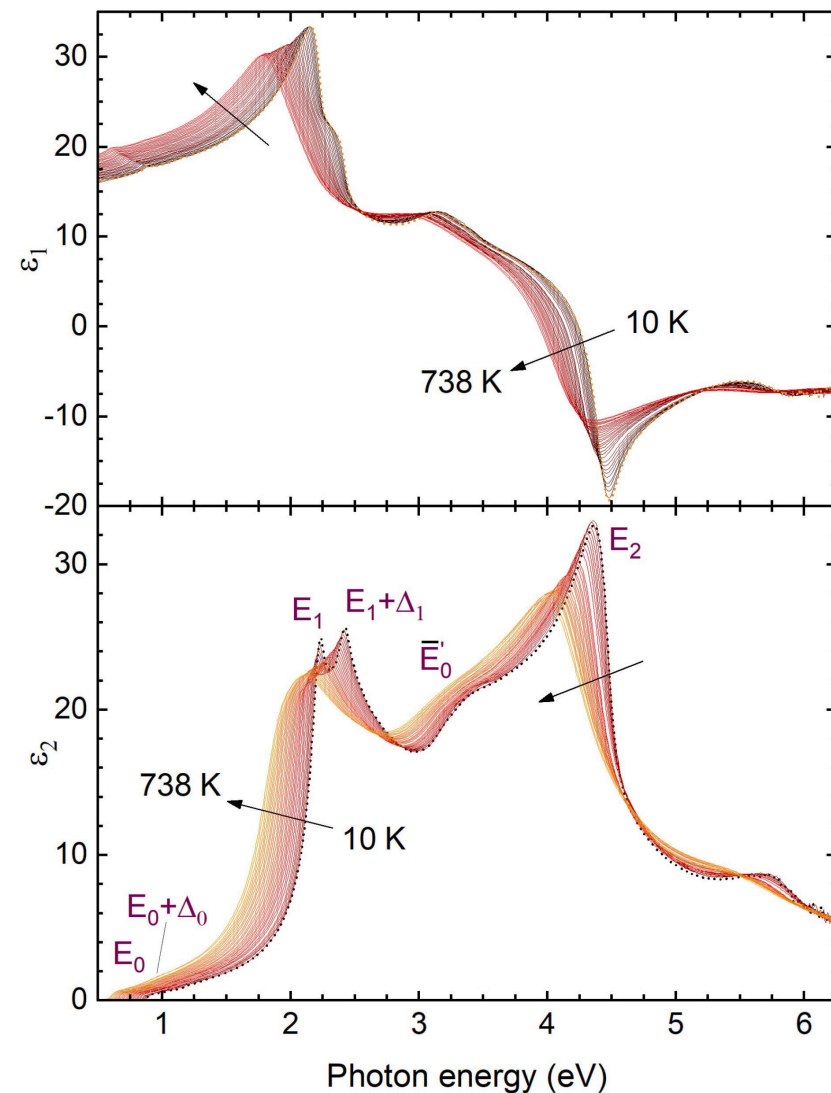
Electrons
scatter from Γ
to X and L



Transient pseudodielectric function from pump-probe spectroscopic ellipsometry



Temperature dependent dielectric function from spectroscopic ellipsometry



S. Espinoza, S. Richter, M. Rebarz, O. Herrfurth, R. Schmidt-Grund, J. Andreasson, S. Zollner, *Appl. Phys. Lett.* **115**, 052105 (2019).

C. Emminger, F. Abadizaman, N.S. Samarasingha, T.E. Tiwald, S. Zollner, *J. Vac. Sci. Technol. B* **38**, 012202 (2020).

Critical point analysis: Second derivatives from linear filters

Ge: E_1 and $E_1 + \Delta_1$

- EG filter width: 12-15 meV
- Fit: 2D-lineshape

$$\epsilon_{2D}(E) = B - Ae^{i\varphi} \ln(E - E_g + i\Gamma)$$

Si: E_1

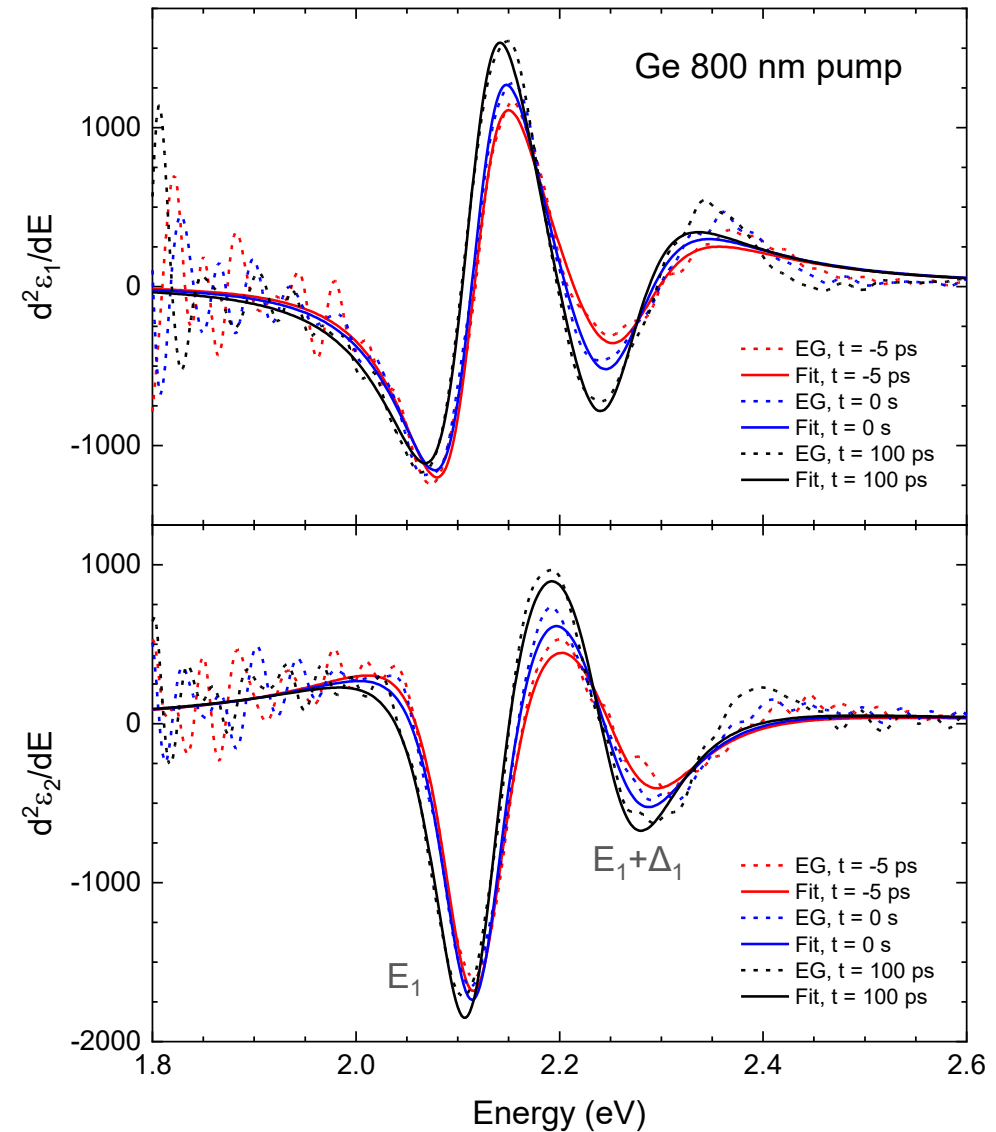
- EG filter width: 20 meV
- Fit: 0D-lineshape

$$\epsilon_{0D}(E) = B - \frac{Ae^{i\varphi}}{E - E_g + i\Gamma}$$

GaSb: E_1 and $E_1 + \Delta_1$

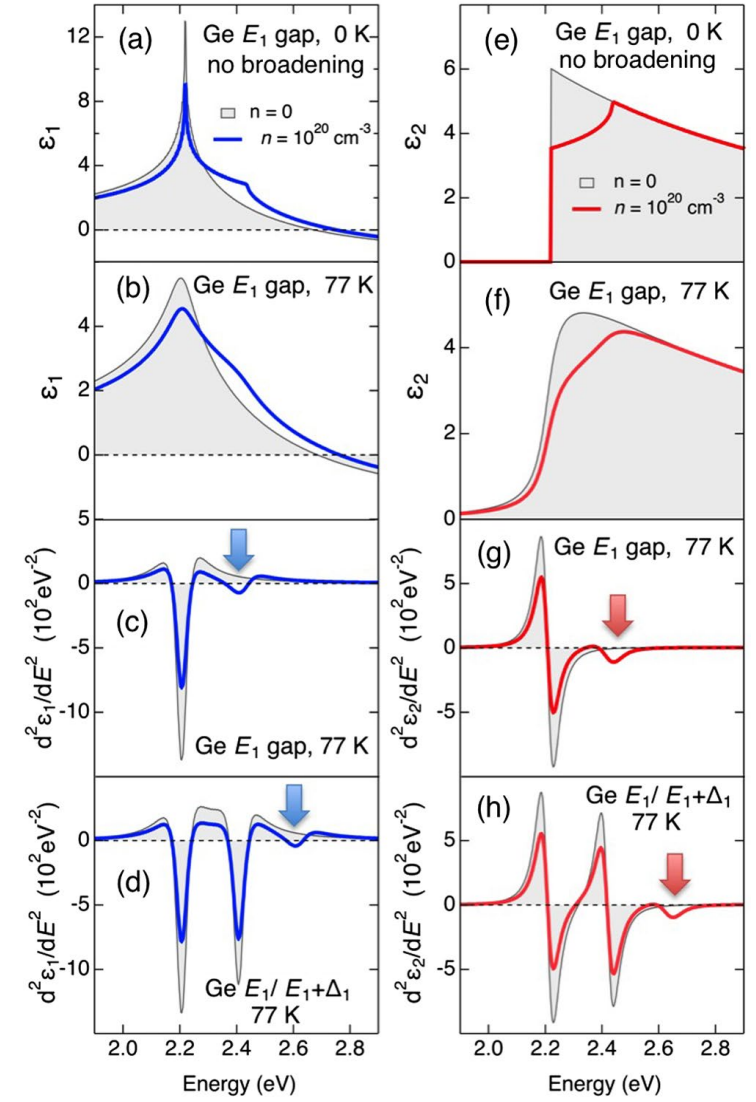
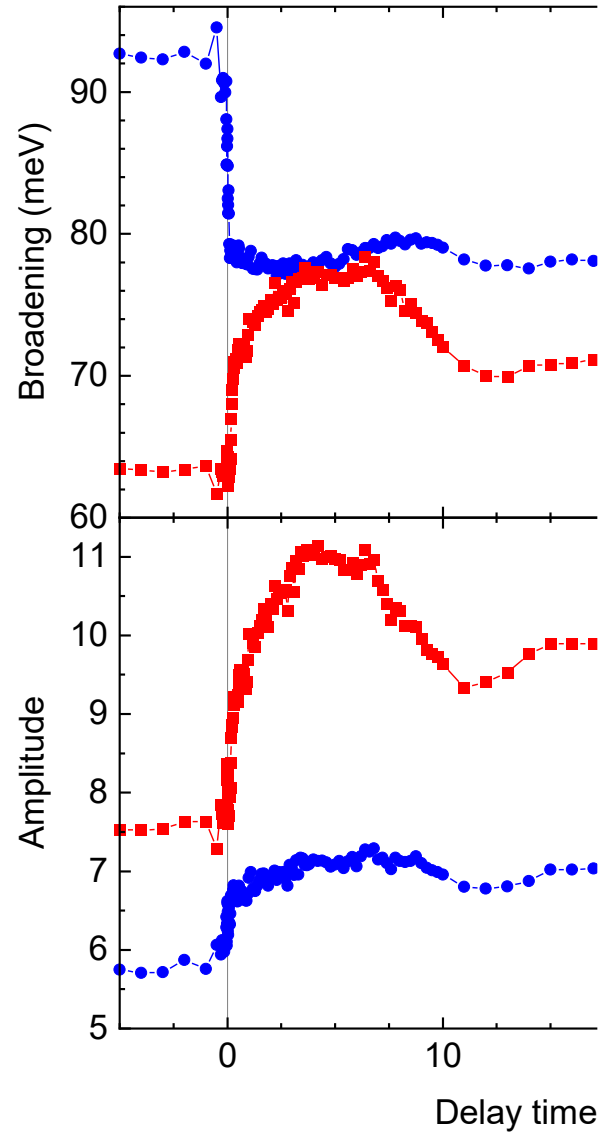
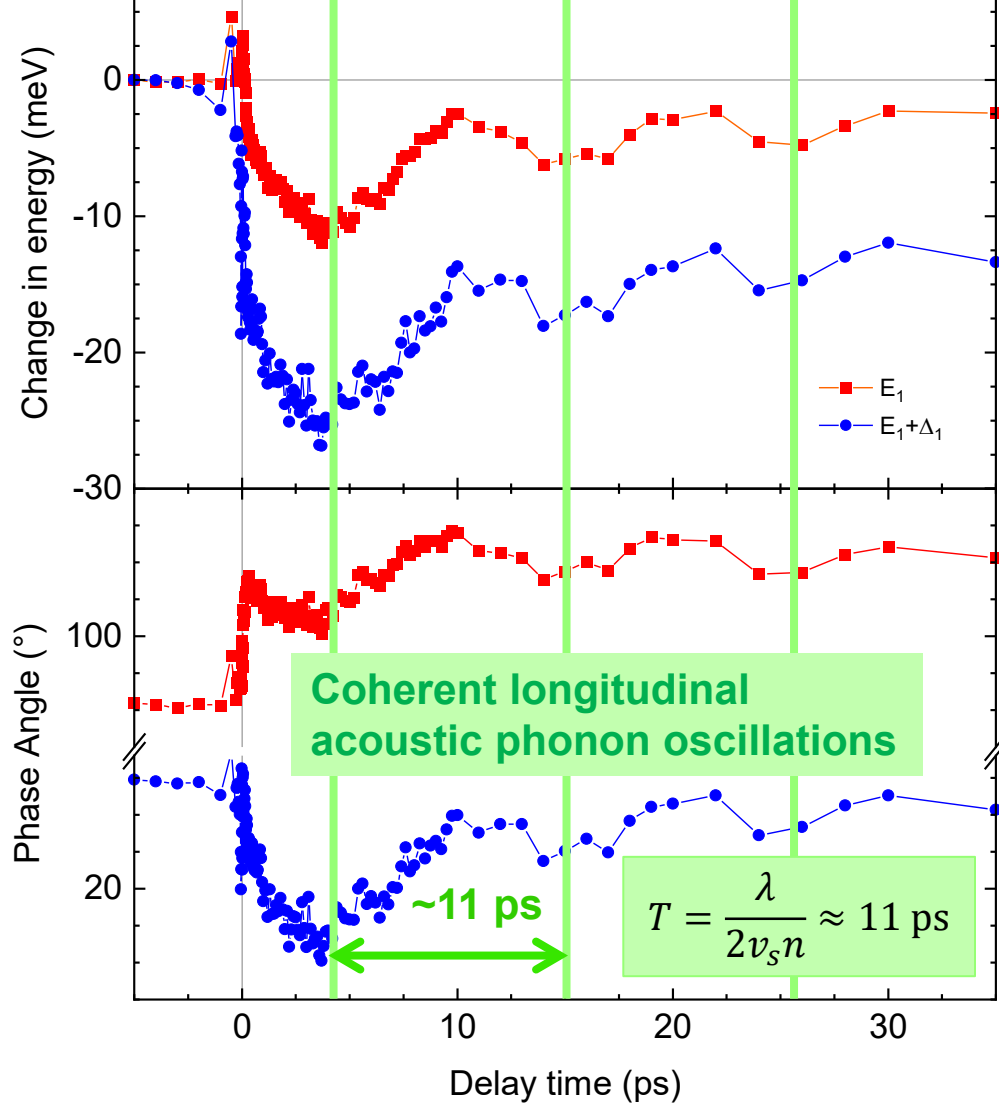
- EG filter width: 10-15 meV
- Fit: 2D-lineshape

=> Better: Lineshape considering bandfilling effects



Critical point parameters as functions of delay time – Ge 800 nm pump

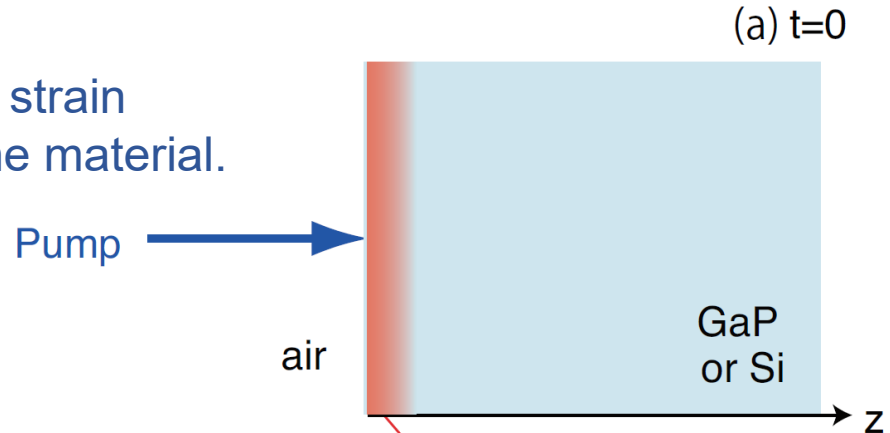
$\Delta E_1 \approx -10 \text{ meV} \Rightarrow \Delta T \approx 20 \text{ K}$
 $\Delta(E_1 + \Delta_1) \approx -25 \text{ meV} \Rightarrow \Delta T \approx 40 \text{ K}$
 $\Delta T \approx \frac{E(1-R)}{cV\rho} \approx 25 \text{ K}$



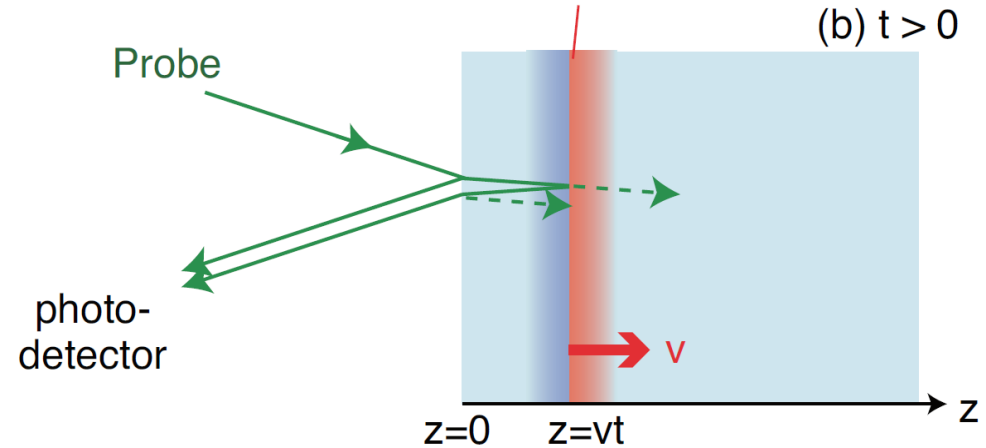
C. Xu, N. S. Fernando, S. Zollner, J. Kouvetakis, and J. Menéndez, Phys. Rev. B **118**, 267402 (2017).

Creation and propagation of a strain pulse

The pump pulse creates strain close to the surface of the material.



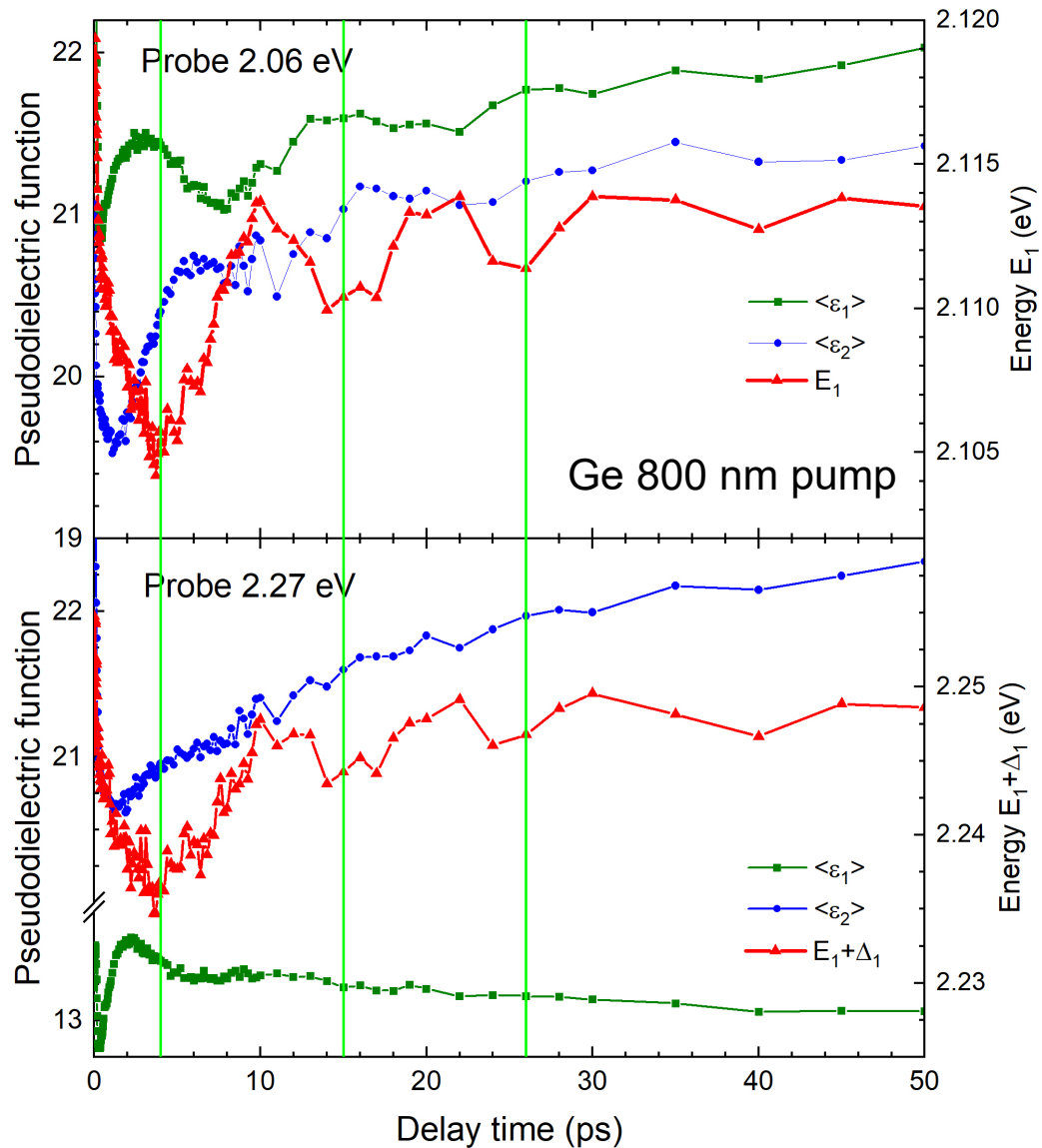
The probe pulse gets reflected by the strain pulse, which moves through the crystal.



Period: $T = \frac{\lambda}{2v_s n}$

λ probe wavelength
 v_s ... longitudinal sound velocity
 n refractive index

Coherent longitudinal acoustic phonon oscillations



→ Oscillations in the CP parameters more pronounced than in the dielectric function

Expected period in various materials:

Ge

E_1

$\lambda = 585 \text{ nm}$

$n = 5.65$

$v_s = 4.87 \times 10^5 \text{ cm/s}$

$T = \frac{\lambda}{2v_s n} \approx 11 \text{ ps}$

$E_1 + \Delta_1$

$\lambda = 550 \text{ nm}$

$n = 5.16$

$v_s = 4.87 \times 10^5 \text{ cm/s}$

$T = \frac{\lambda}{2v_s n} \approx 11 \text{ ps}$

Si

$\lambda = 365 \text{ nm}$

$n = 6.52$

$v_s = 8.43 \times 10^5 \text{ cm/s}$

$T = \frac{\lambda}{2v_s n} \approx 3.3 \text{ ps}$

InP

$\lambda = 390 \text{ nm}$

$n = 3.98$

$v_s = 4.58 \times 10^5 \text{ cm/s}$

$T = \frac{\lambda}{2v_s n} \approx 11 \text{ ps}$

GaSb

E_1

$\lambda = 620 \text{ nm}$

$n = 5.24$

$v_s = 4 \times 10^5 \text{ cm/s}$

$T = \frac{\lambda}{2v_s n} \approx 15 \text{ ps}$

$E_1 + \Delta_1$

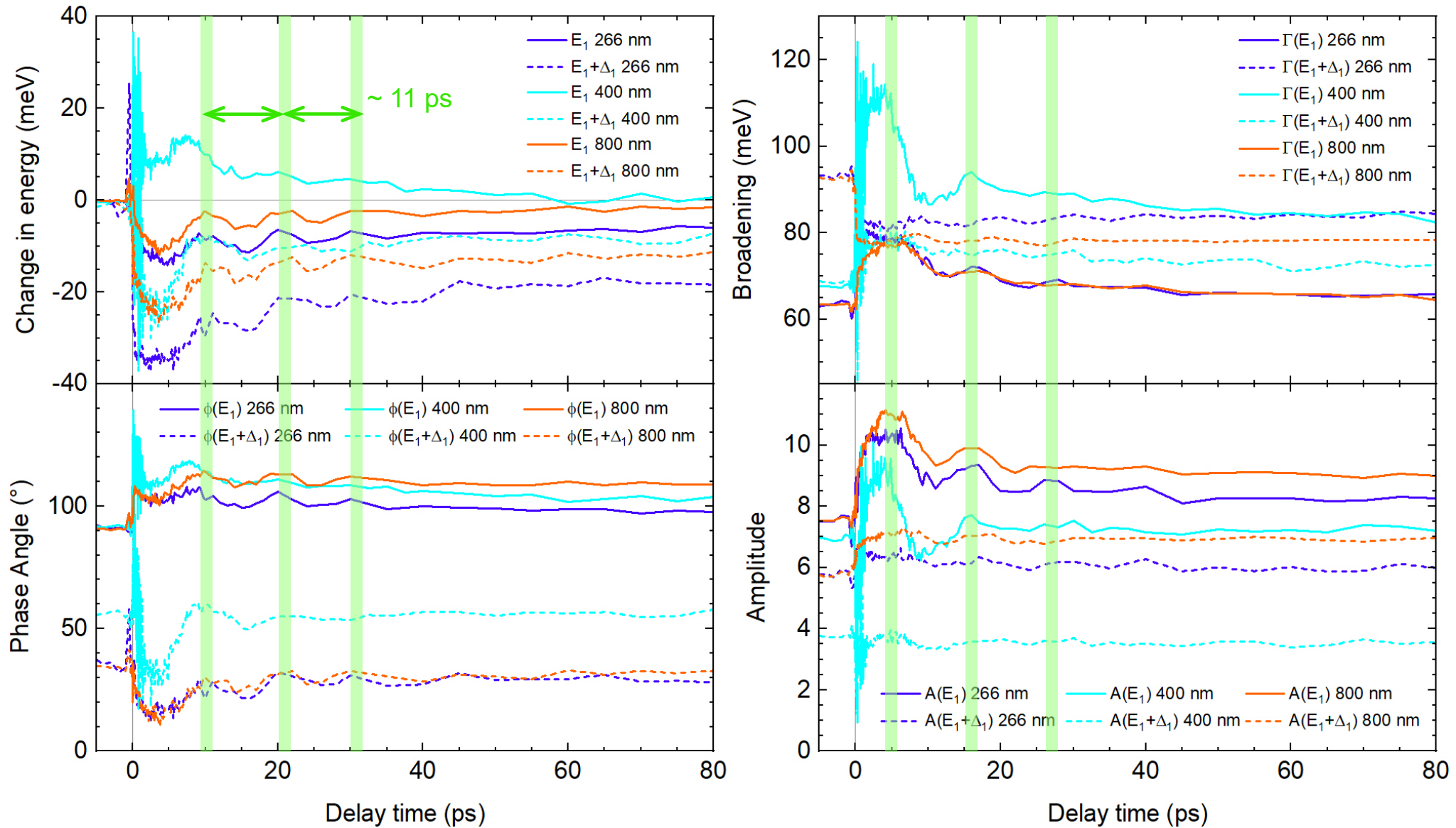
$\lambda = 510 \text{ nm}$

$n = 4.45$

$v_s = 4 \times 10^5 \text{ cm/s}$

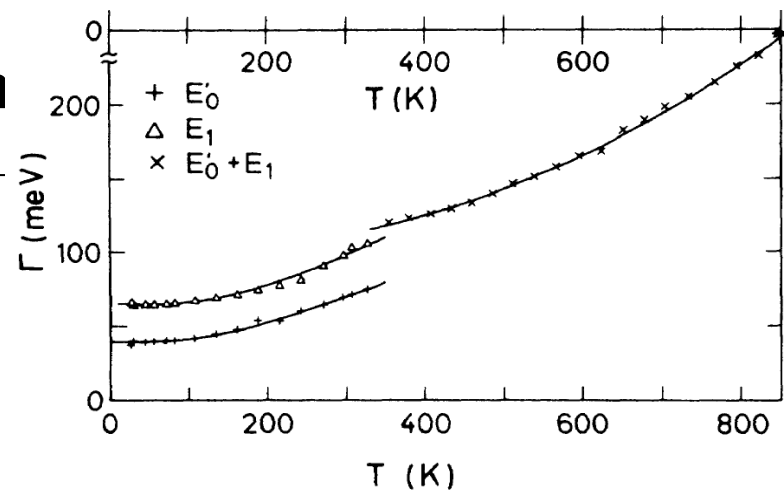
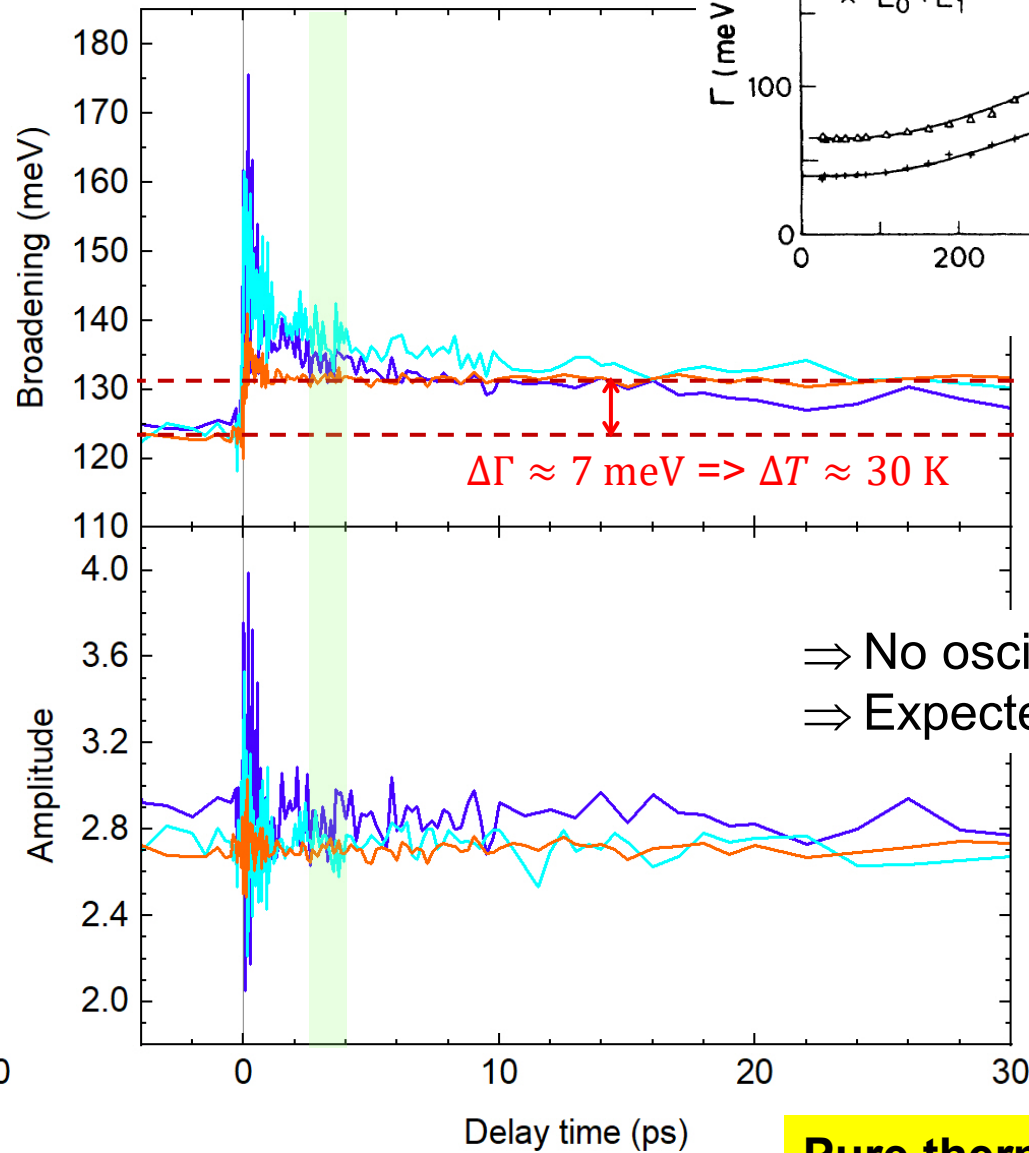
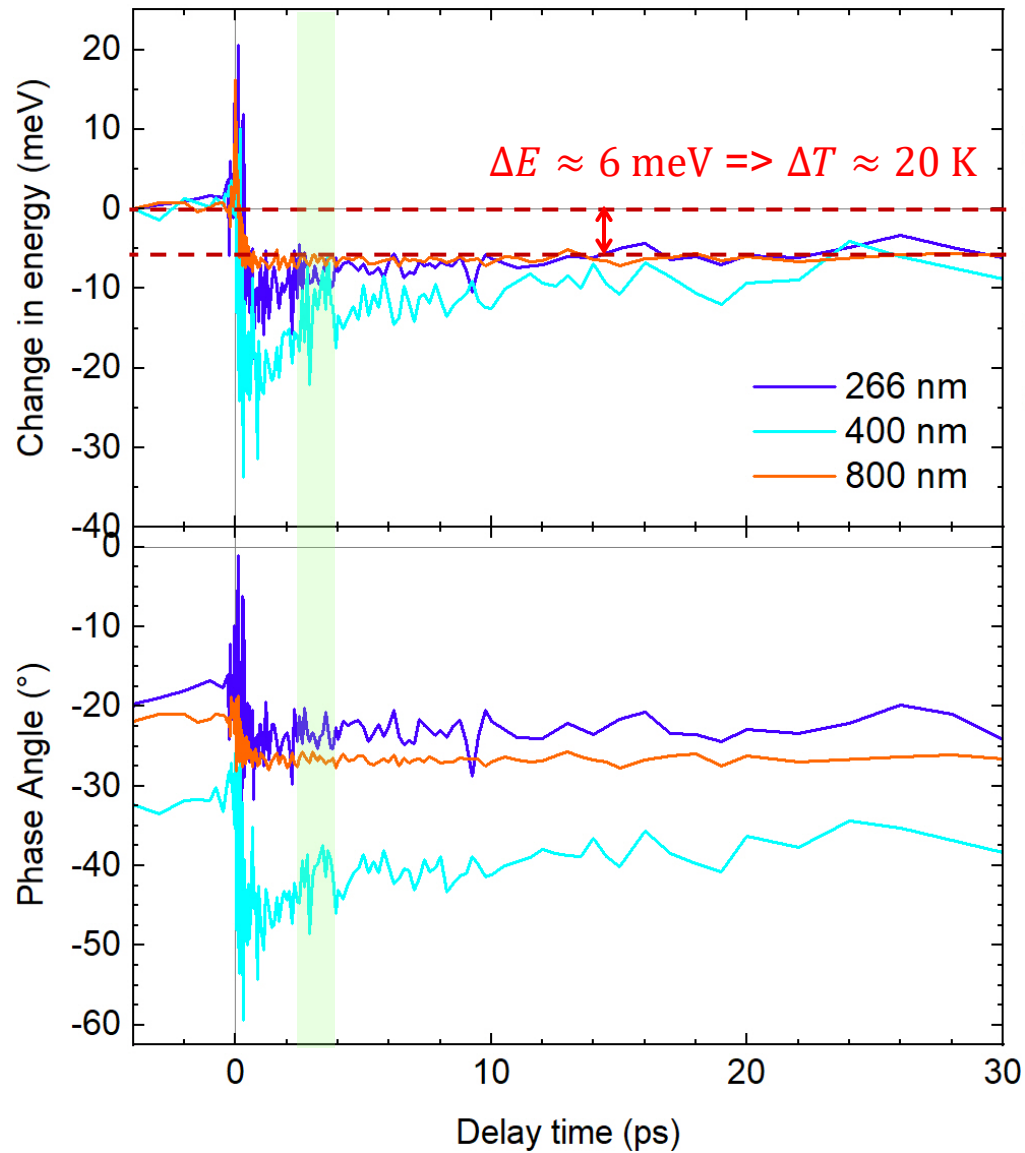
$T = \frac{\lambda}{2v_s n} \approx 14 \text{ ps}$

Critical point parameters of Ge (266, 400, and 800 nm pump)



=> Oscillations present in all Ge data sets (266, 400, and 800 nm pump)

Critical point parameters of Si (266, 400, and 800 nm pun

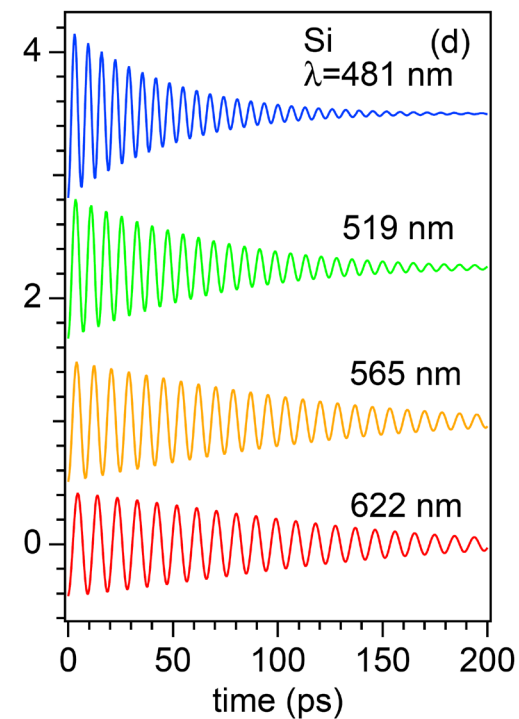
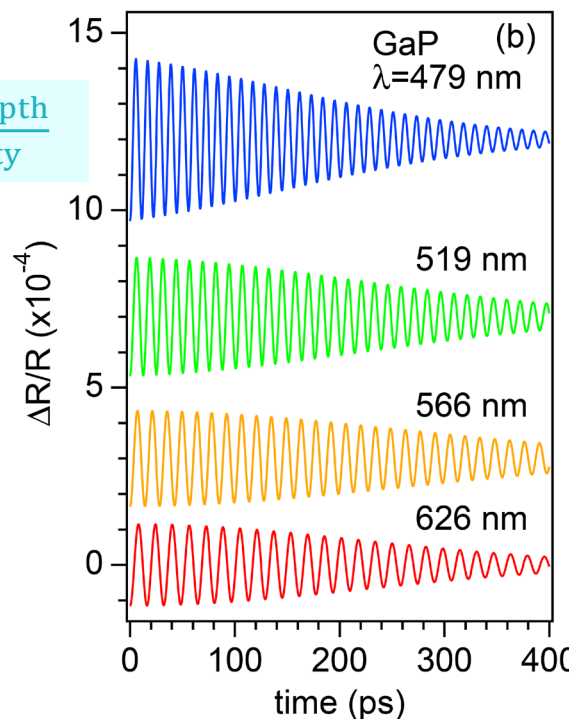
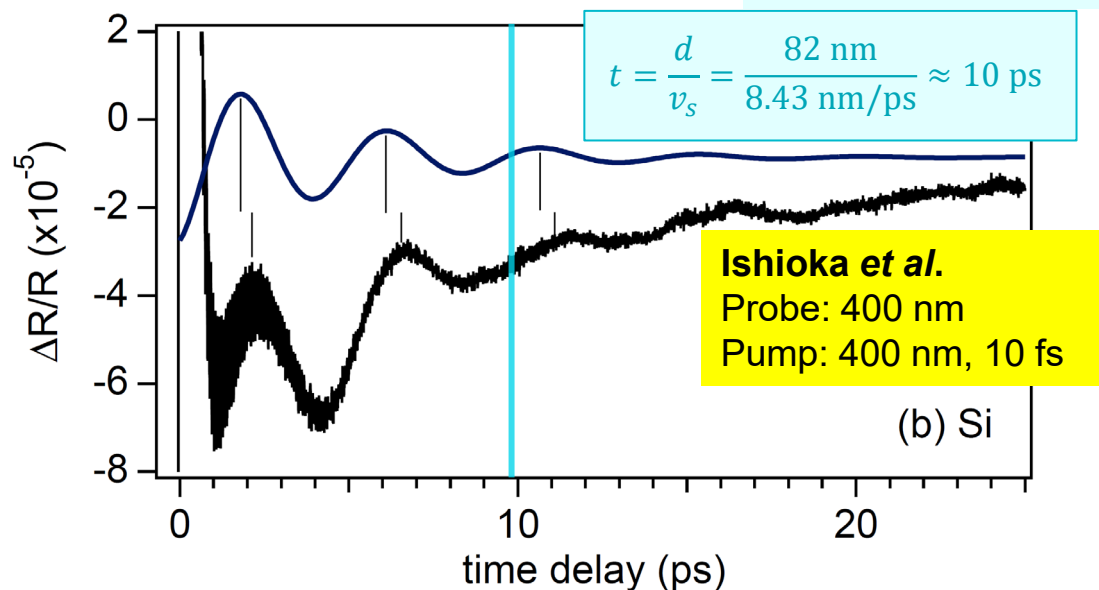
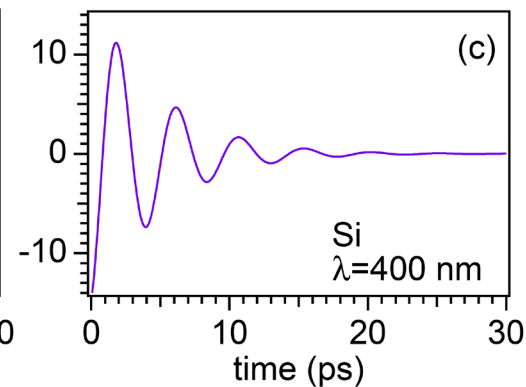
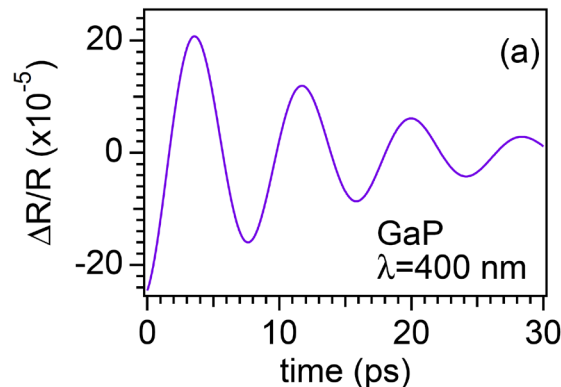
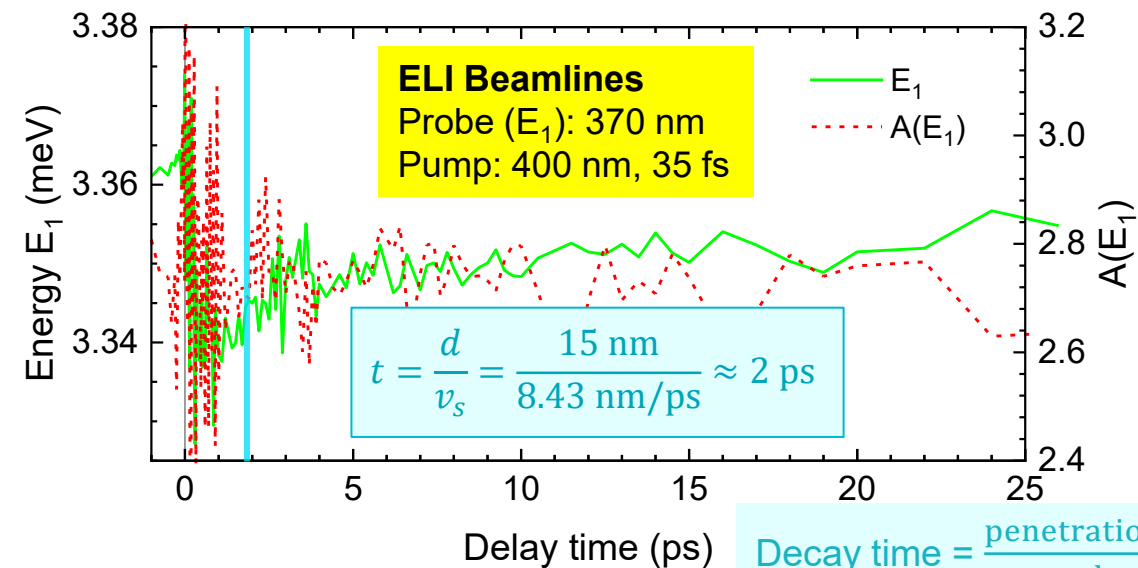


\Rightarrow No oscillations detected
 \Rightarrow Expected period:

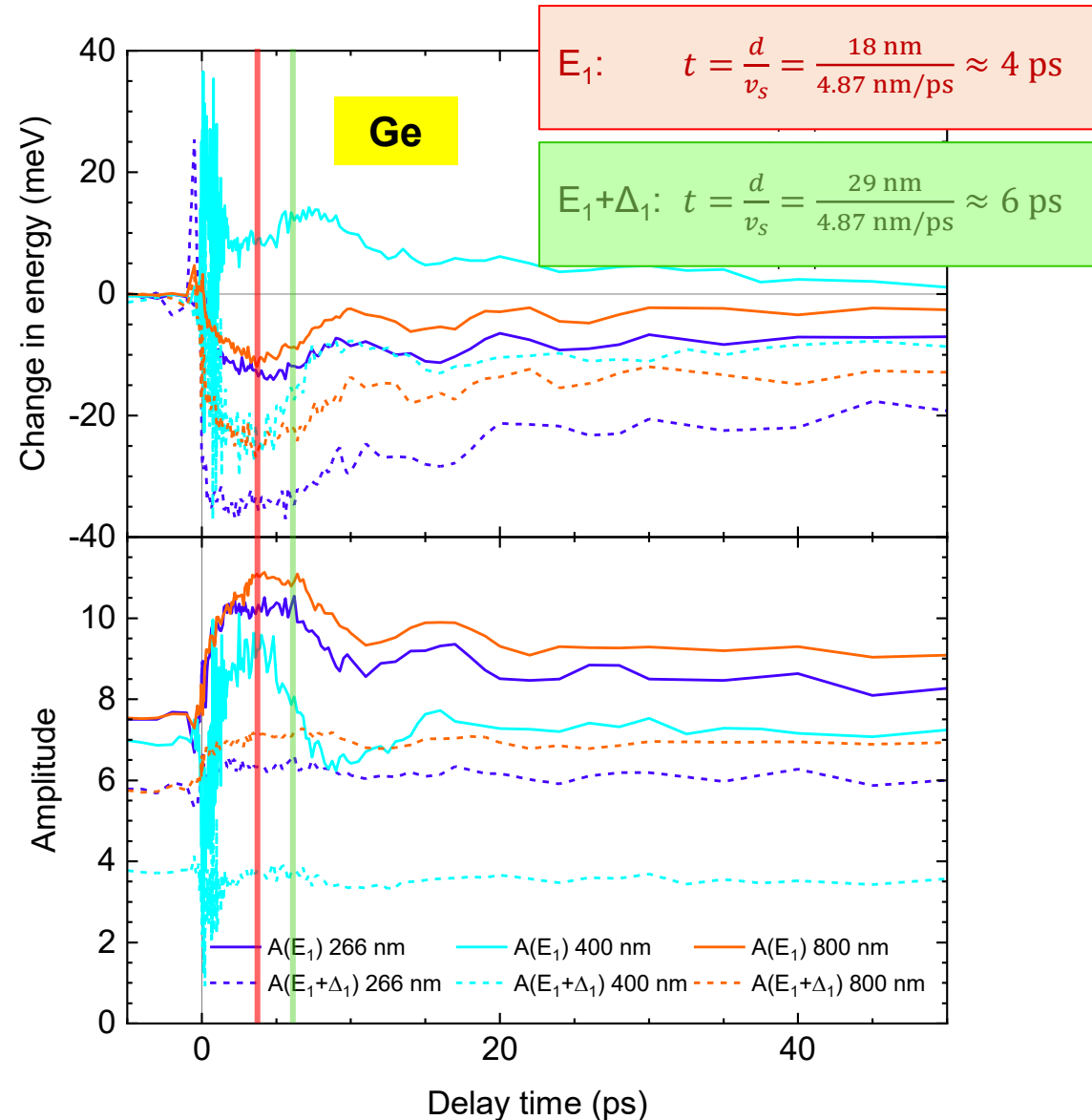
$$T = \frac{\lambda}{2v_s n} \approx 3 \text{ ps}$$

Pure thermal effect

Coherent longitudinal acoustic phonon oscillations in Si

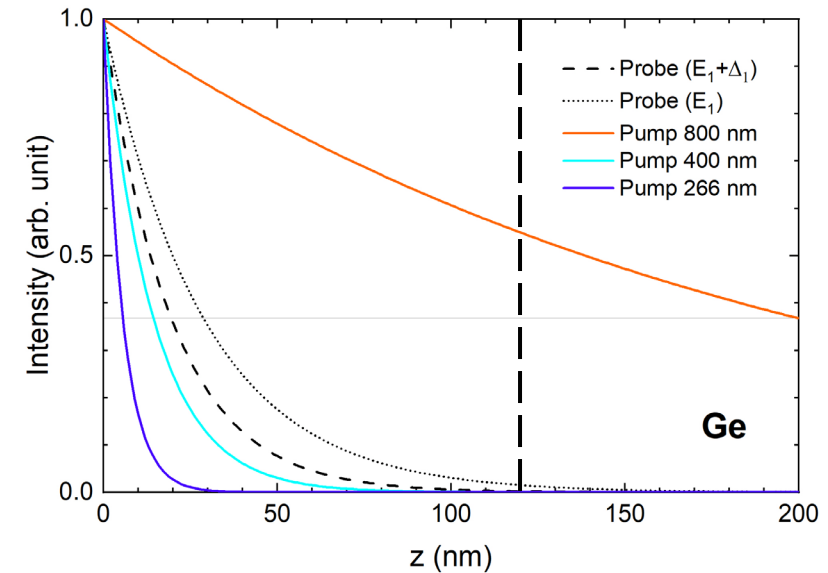


Propagation of strain pulses in Ge



Oscillations in the CP parameters seen up to about 25 ps:

$$d = 25 \text{ ps} \cdot 4.87 \frac{\text{nm}}{\text{ps}} \approx 120 \text{ nm}$$



Next step: Determine expected amplitude of coherent LA phonon oscillations

Summary



Part 1

- **Excitonic effects at the direct band gap E_0 of Ge**
 - Good agreement between model and data despite having only two fit parameters (energy and broadening).
 - Possible application to other semiconductors.

Part 2

- **Temporal evolution of E_1 and $E_1+\Delta_1$ in Ge**
 - Oscillations in CP parameters due to coherent longitudinal acoustic phonons.
- **Temporal evolution of CP parameters in Si**
 - No phonon oscillations detected.
- **Outlook & future work**
 - Taking new data with time steps targeted to resolve phonon oscillations.
 - Tunable pump wavelength.
 - Investigating bandfilling effects.



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M U N I

